

Sub D³
3. (Four times amended) A liquid crystal display device comprising a switching element formed on a substrate, a pixel electrode connected to said switching element, and a reflection layer,

wherein said pixel electrode is formed of a transparent conductive film, and wherein said reflection layer formed of a dielectric multi-layer film is provided under said pixel electrode, and

wherein said pixel electrode has a thickness of 50.5 nm to 88.4 nm, and said thickness is satisfied by $\lambda/4$, wherein $\lambda/4$ satisfies a relation of $nd = \lambda/4$, where n is a refractive index, d is a film thickness, and λ is a center wavelength.

Sub D⁴
5. (Four times amended) A liquid crystal display device comprising a switching element formed on a substrate, a pixel electrode connected to said switching element, and a reflection layer,

wherein said switching element is connected to a capacitance, wherein said capacitance comprising a common electrode formed of a transparent conductive film, a dielectric film formed on said common electrode, and said pixel electrode formed of a transparent conductive film formed on said dielectric film,

wherein said reflection layer formed of a dielectric multi-layer film is provided below said common electrode, and

wherein said pixel electrode has a thickness of 50.5 nm to 88.4 nm, and said thickness is satisfied by $\lambda/4$, wherein $\lambda/4$ satisfies a relation of $nd = \lambda/4$, where n is a refractive index, d is a film thickness, and λ is a center wavelength.

Sub D⁵
8. (Four times amended) A method of manufacturing a liquid crystal display device, comprising the steps of:

forming a switching element formed on a substrate; a reflection layer formed of a dielectric multi-layer film above said switching element; and,